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Recent Advances in Modeling and Control of Air Pollutants Dispersion and Source Tracking

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Message from the Guest Editor

The significant adverse effects of air pollutants on both human health and environmental quality necessitate the exploration and implementation of novel and effective control and simulation technologies for air pollutant management, thereby reducing the impact of these pollutants on local communities. In this Special Issue, titled “Recent Advances in Modeling and Control of Air Pollutants Dispersion and Source Tracking”, we aim to elucidate how innovative simulation and control methods can be applied to air pollutants dispersion and pollutant source tracking. This Special Issue is of invaluable importance to governments as it contributes to the advancement of air quality management strategies for the future.



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Special Issue



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Message from the Editor-in-Chief

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